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(54) Title: ELECTROSTATIC CLAMP, LITHOGRAPHIC APPARATUS AND METHOD OF MANUFACTURING AN ELECTROSTATIC CLAMP

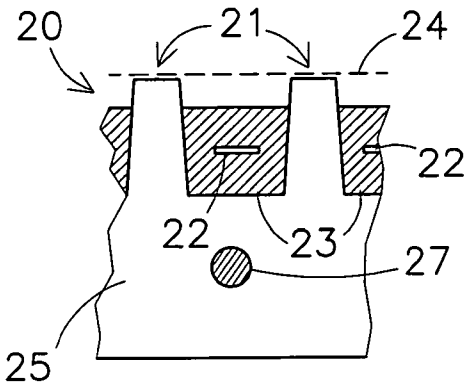


Fig. 4

(57) Abstract: The invention relates to an electrostatic clamp for use in a lithographic apparatus comprising a layer of material provided with burls, wherein an electrode surrounded by an insulator and or a dielectric material is provided in between the burls and a method of manufacturing such an electrostatic clamp. The electrostatic clamp may be used to clamp an object to an object Support in a lithographic apparatus.

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